	Notice of Allowability	Application No.	Applicant(s) CHO ET AL.	
		09/923,670		
		Examiner	Art Unit	
		Toniae M. Thomas	2822	
All claims being erewith (or prev NOTICE OF ALI	ne MAILING DATE of this communication allowable, PROSECUTION ON THE MEIN viously mailed), a Notice of Allowance (Paulice of Allowance) and perint of PAILING perint of the applicant. See 37 CF	RITS IS (OR REMAINS) CLOSED in TOL-85) or other appropriate commu TENT RIGHTS. This application is so	this application. If not inclination will be mailed in	cluded due course. THIS

herewith (or previously mailed), a Notice of Allowance (PTOL-85) or othe NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. of the Office or upon petition by the applicant. See 37 CFR 1.313 and M	This application is subject to withdrawal from issue at the initiative
1. This communication is responsive to the amendment filed on 12/0	<u>04/03</u> .
2. The allowed claim(s) is/are <u>58-72 and 74-77</u> .	
3. Main The drawings filed on <u>07 August 2001</u> are accepted by the Exami	ner.
4. Acknowledgment is made of a claim for foreign priority under 35	U.S.C. § 119(a)-(d) or (f).
a) ⊠ All b) ☐ Some* c) ☐ None of the:	
 Certified copies of the priority documents have been in 	received.
2. Certified copies of the priority documents have been in	received in Application No
Copies of the certified copies of the priority document	s have been received in this national stage application from the
International Bureau (PCT Rule 17.2(a)).	
* Certified copies not received:	
5. Acknowledgment is made of a claim for domestic priority under 35 reference was included in the first sentence of the specification or	U.S.C. § 119(e) (to a provisional application) since a specific in an Application Data Sheet. 37 CFR 1.78.
(a) The translation of the foreign language provisional applicati	
 Acknowledgment is made of a claim for domestic priority under 35 in the first sentence of the specification or in an Application Data S 	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this co below. Failure to timely comply will result in ABANDONMENT of this app	mmunication to file a reply complying with the requirements noted blication. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.
 A SUBSTITUTE OATH OR DECLARATION must be submitted. N INFORMAL PATENT APPLICATION (PTO-152) which gives reason 	ote the attached EXAMINER'S AMENDMENT or NOTICE OF on(s) why the oath or declaration is deficient.
 8. CORRECTED DRAWINGS (as "replacement sheets") must be sull (a) including changes required by the Notice of Draftsperson's Path 1) hereto or 2) to Paper No (b) including changes required by the proposed drawing correction (c) including changes required by the attached Examiner's Amen 	atent Drawing Review (PTO-948) attached on filed, which has been approved by the Examiner.
Identifying indicia such as the application number (see 37 CFR 1.84(c)) seach sheet. Replacement sheet(s) should be labeled as such in the marg	should be written on the drawings in the front (not the back) of jin according to 37 CFR 1.121(d).
9. DEPOSIT OF and/or INFORMATION about the deposit of B attached Examiner's comment regarding REQUIREMENT FOR THE DEF	SIOLOGICAL MATERIAL must be submitted. Note the POSIT OF BIOLOGICAL MATERIAL.
Attachment(s)	
1 Notice of References Cited (PTO-892)	5☐ Notice of Informal Patent Application (PTO-152)
2☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6☐ Interview Summary (PTO-413), Paper No
3 Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No	7 Examiner's Amendment/Comment
4 Examiner's Comment Regarding Requirement for Deposit of Biological Material	8⊠ Examiner's Statement of Reasons for Allowance 9□ Other

Application/Control Number: 09/923,670

Art Unit: 2822

Reasons for Allowance

The following is an examiner's statement of reasons for allowance: claims 62-69 and 77 are allowable over the prior art of record for reasons made of record in the action mailed on 16 September 2003. Claims 58-61, 70-72, and 74-76 are allowable because the prior art of record does not anticipate or render obvious a method of forming a protective structure for a ferroelectric dielectric region on an integrated circuit substrate substantially as claimed, wherein the method comprises depositing a non-conductive second metal oxide layer on the first metal oxide layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toniae M. Thomas whose telephone number is (571) 272-1846. The examiner can normally be reached on Monday through Thursday from 8:30 AM to 5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on (571) 272-1852. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (571) 272-1675.

JMJ 12 January 2004

